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MS ISSUE FEE PATENT 0171-1026P

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant:

Satoshi OKAZAKI et al.

Group:

1775

Application No.:

DEC 1 1 2006

10/679,264

Examiner:

Elizabeth D. Ivey

Filed:

October 7, 2003

Conf.:

3127

For:

HALFTONE PHASE SHIFT MASK BLANK, AND METHOD OF

MANUFACTURE

LETTER REQUESTING INITIALED PTO 1449 FORM

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

DEC 1 1 2006

Sir:

In reviewing the above-captioned application file upon allowance, the undersigned has noted that even though acknowledgement was received for the PTO Form 1449 filed on June 23, 2004, the Examiner did not initial the reference under "Other Documents". No reason was given as to why this reference was not initialed.

The Patent and Trademark Office therefore is requested to return the initialed form to the undersigned as soon as possible.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 02-2448 for any additional fees required under 37 C.F.R. §1.16 or under 37 C.F.R. §1.17; particularly, extension of time fees.

Respectfully submitted,

BIRCH, STEWART, KOLASCH & BIRCH, LLP

OERALD M. MURPHY, JR., #

P.O. Box 747 Falls Church, VA 22040-0747 (703) 205-8000

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